

STRAIN INDUCED BAND GAPS IN GRAPHENE NANO RIBBONS

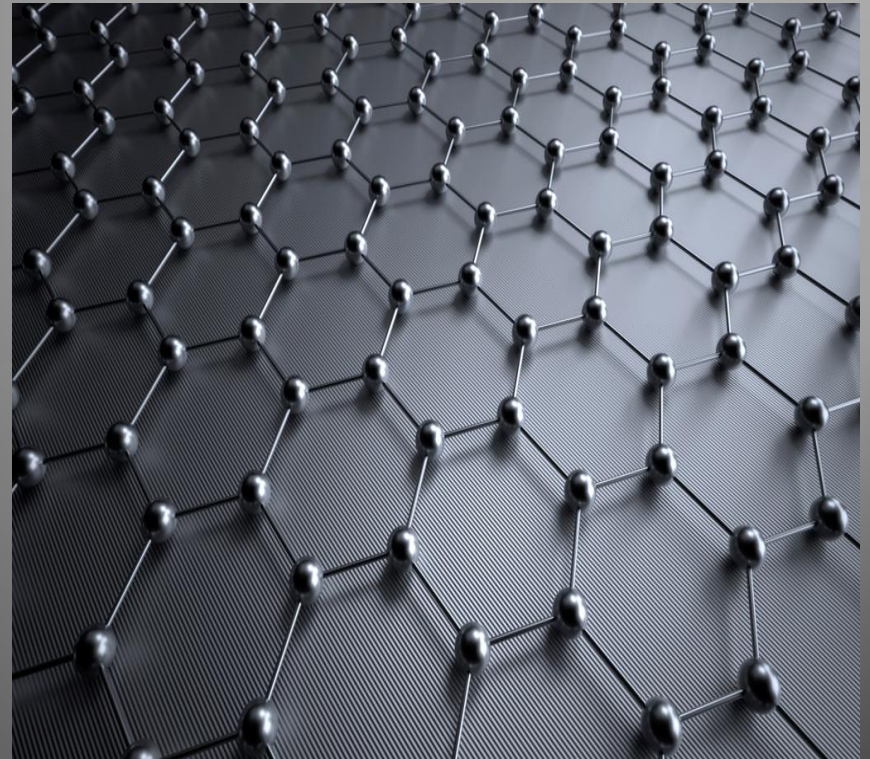
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WHAT IS GRAPHENE?

- ▶ An allotrope of carbon
- ▶ Arranged in perfectly hexagonal lattice.
- ▶ Just one atom thick
- ▶ A 2-dimensional material.



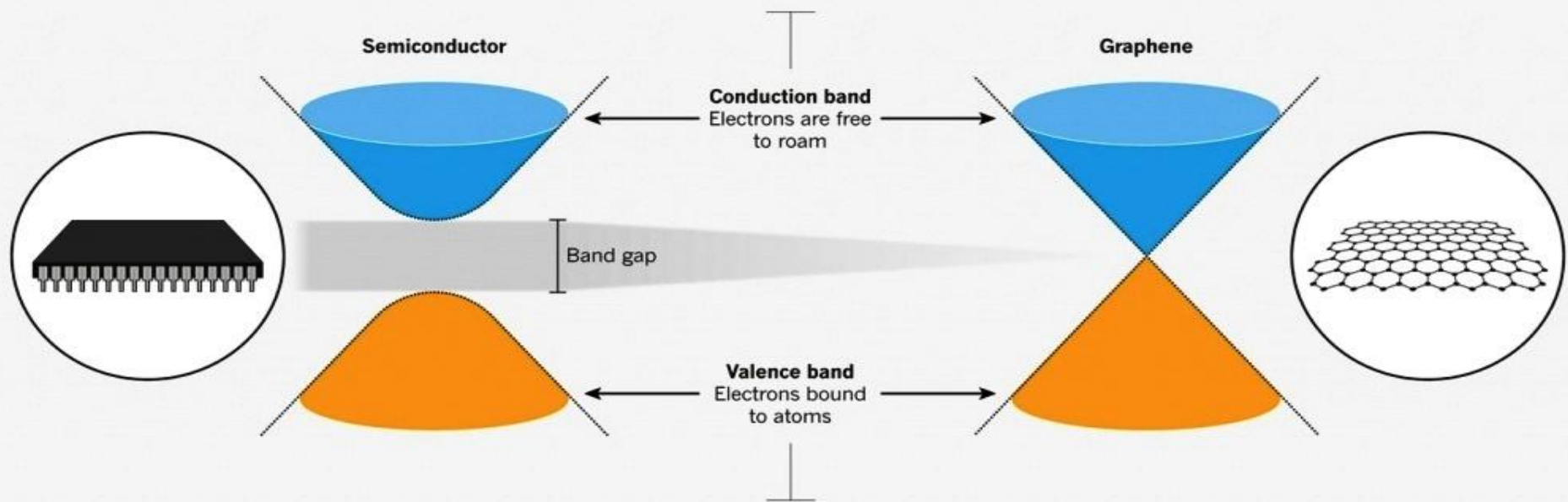
Remarkable properties.....

- ▶ Thinnest, lightest as well as strongest material known
- ▶ Conducts electricity better than almost any other material
- ▶ Extremely flexible
- ▶ Transmits almost 97.7 % of light
- ▶ The energy–momentum dispersion is linear in graphene leads to very high electron mobility
- ▶ Can be used in numerous applications as in automobile field, satellite navigation, medical field etc

Biggest Disadvantage:

Zero band gap:

- ▶ The conduction band touches the valence band at the Fermi level
- ▶ Therefore no threshold energy is required to move electrons from the conduction band to valence band.



- ▶ Due to zero band gap, there is no stoppage of electrons inside Graphene at applied gate voltage, which limits its application in the field of electronics.
- ▶ If we could open and tune the band gap, then graphene can be used as a semiconductor with great efficiency.

Graphene Nano Ribbons (GNRs)....

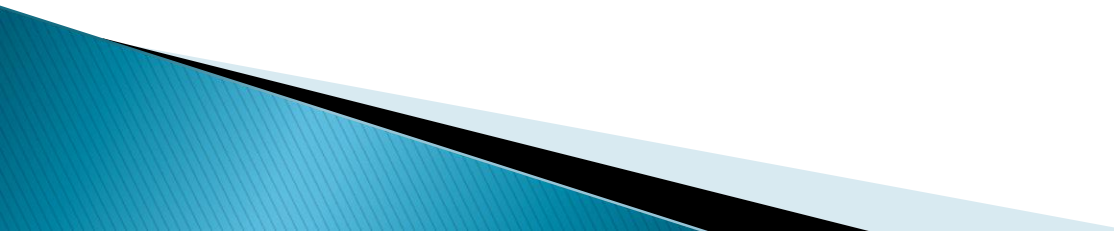
- ▶ GNRs are 1-D graphene nanostructures with extremely thin width.
- ▶ Due to confinement of charge carriers, a band gap can be opened in Graphene Nano Ribbons.
- ▶ Two kinds of GNRs:
 - a) ZIGZAG GNRs (ZGNRs)
 - b) ARMCHAIR GNRs (AGNRs)

- ▶ **Aim of this project:**

- i)* To tune band gap in ZGNRs with permissible strain

- ii)* To observe corresponding change in its electronic properties

Tools

- ▶ We use DFT (Density Functional Theory) with VASP for theoretical band structure calculation.
 - ▶ DFT deals with ground state energy as a functions of density of electrons.
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Density Functional Theory

- ▶ To obtain approximate solution of many body Schrodinger equation
- ▶ Electronic ground state structure in terms of electronic density distribution

$$H \psi(x_1, x_2, \dots, x_N, R_1, R_2, \dots, R_M) = E \psi(x_1, x_2, \dots, x_N, R_1, R_2, \dots, R_M)$$

$$H = -\frac{1}{2m_e} \sum_i \nabla_i^2 - \frac{1}{2m_n} \sum_j \nabla_j^2 + \frac{1}{2} \sum_{\substack{i,k \\ i \neq k}} \frac{e^2}{r_i - r_k} + \frac{1}{2} \sum_{\substack{j,l \\ j \neq l}} \frac{Z_j Z_l e^2}{r_j - r_l} - \sum_{i,k} \frac{Z_i e^2}{r_i - r_k}$$

$$H = T_e + T_n + V_{ee} + V_{nn} + V_{en}$$

- ▶ Born–Oppenheimer approximation:

$$T_n = 0; V_{nn} = \text{constant} \Rightarrow$$

$$H = T_e + V_{ee} + V_{en}$$

- ▶ Kinetic energy can be approximated as a function of density such that

$$E(n, r) = F(n) + \int V_{ext}(r)n(r)dr + V_{ee}(r) + V_{en}(r)$$

- ▶ DFT uniquely determines the ground state energy by minimizing the energy and by playing with the density.

▶ **VASP (Vienna Ab Initio Simulation Package).**

▶ **Input parameters:**

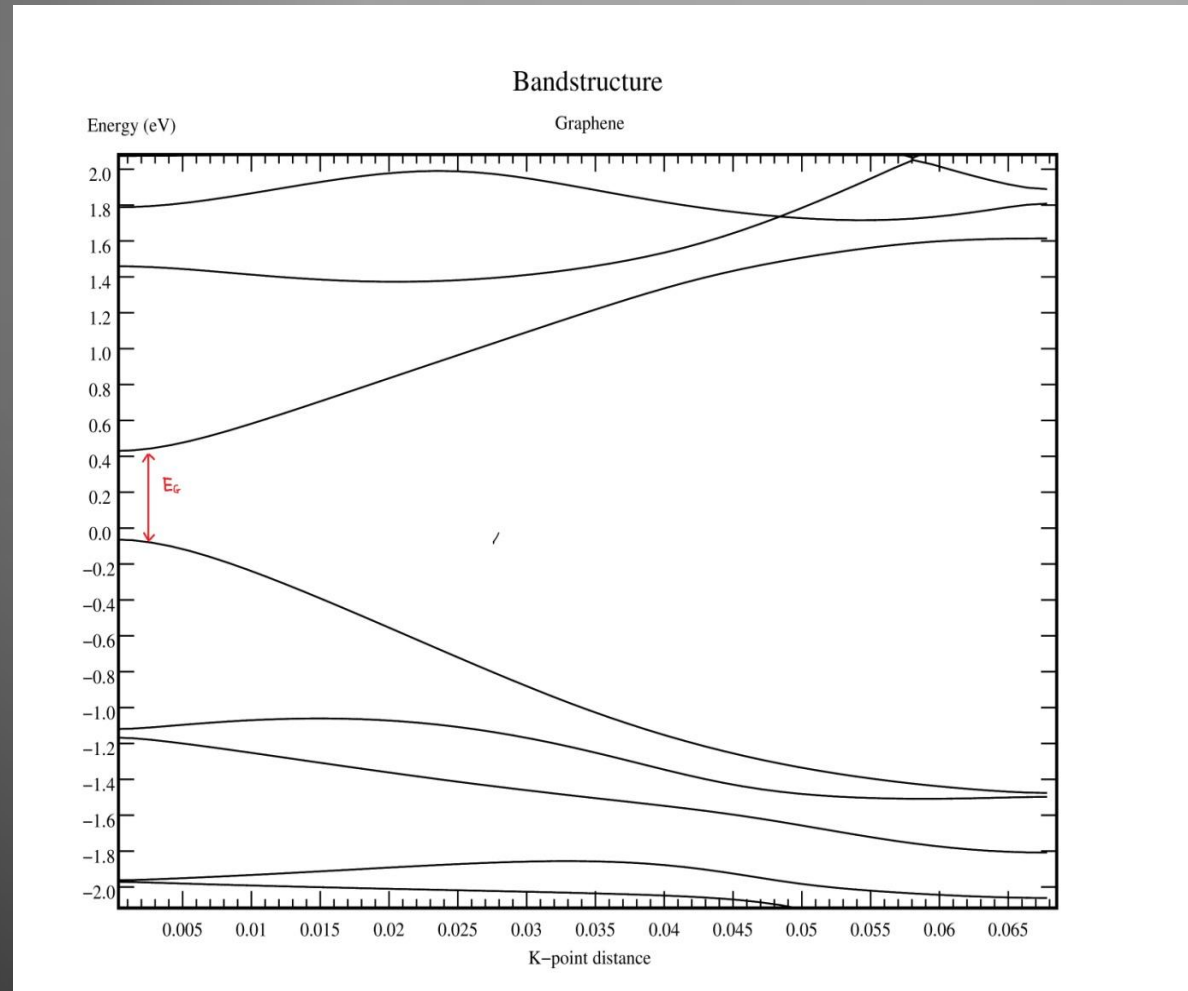
1. **INCAR:** central input file of VASP contains input parameters, which determines what to do and how to do.
2. **POSCAR:** it contains the positions of the ions;
3. **KPOINTS:** it contains K Points in k-points coordinates.
4. **POTCAR:** this file contains potentials and information about atoms, their masses, valence electrons.

▶ **Calculations.....**

1. **Relaxation:** an optimization step, to relax the structure.
2. **Self consistent calculation:** this step provides the charge density and the free energy of the system.
3. **Non self consistent calculation:** using the charge density provided by second step, this step calculates the band structure.

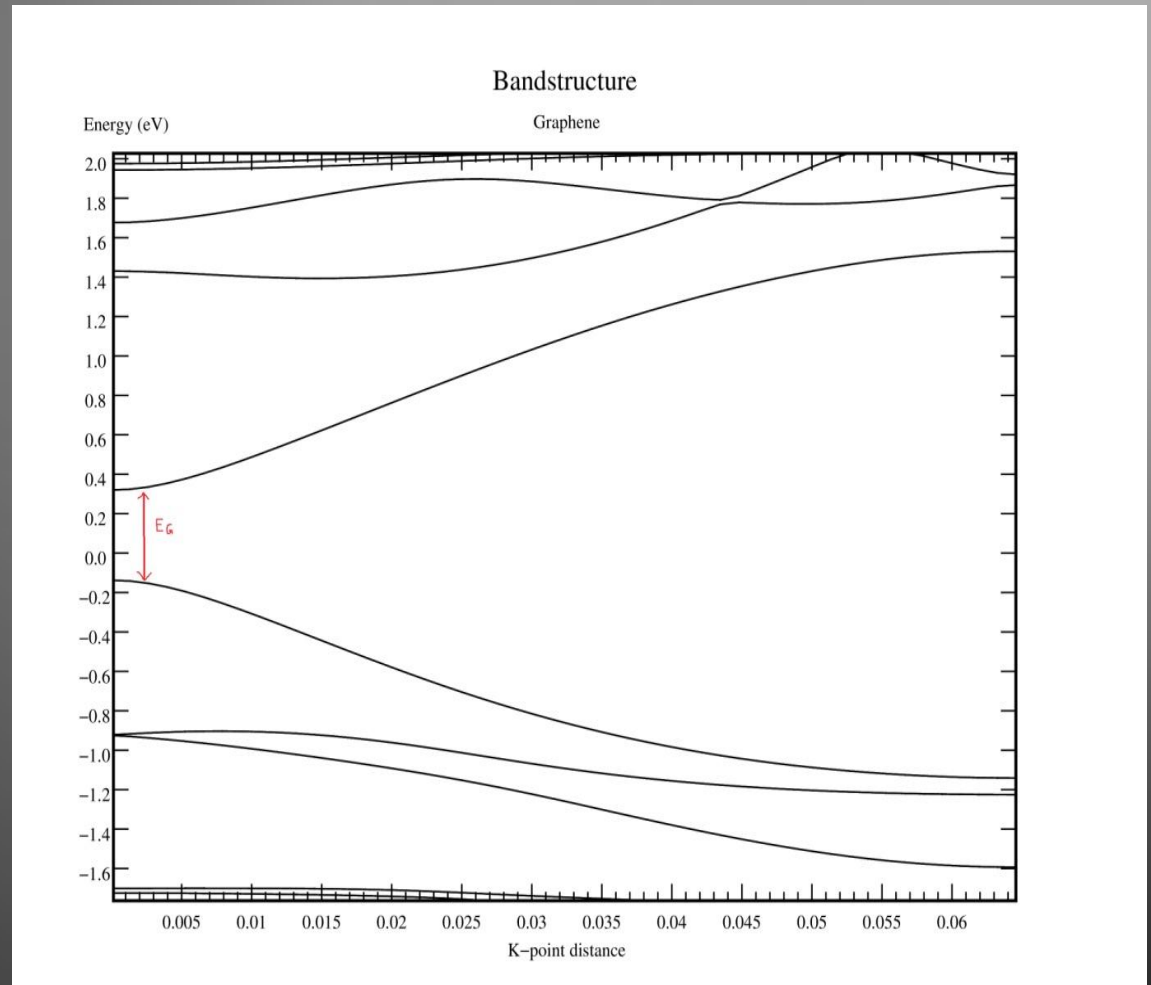
OBSERVATIONS:

- ▶ 3-ZGNRs
- ▶ 0% strain (original state):
- ▶ band gap between lowermost valance band and uppermost conduction band near the Fermi level is present (semi conducting)



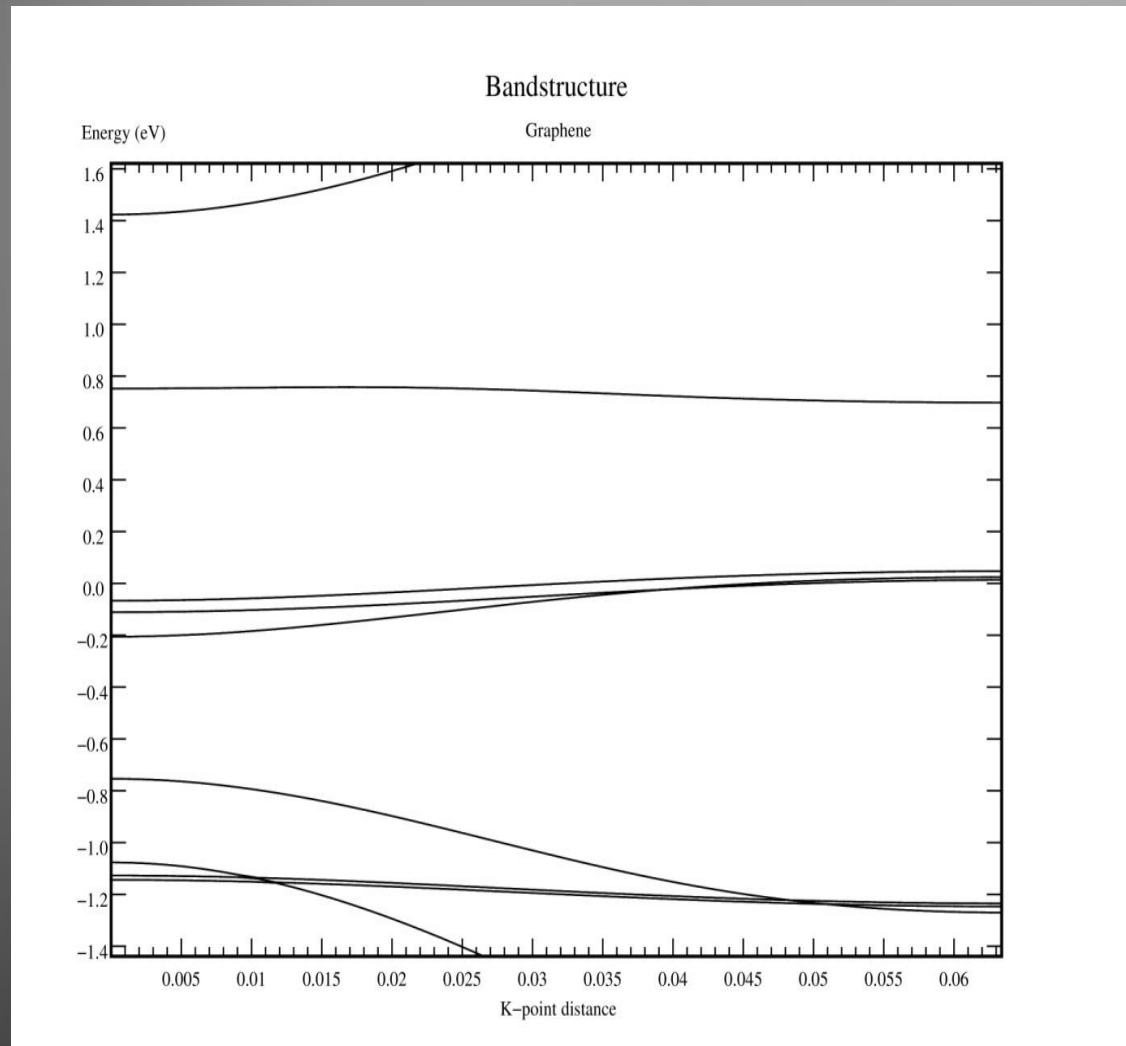
OBSERVATIONS:

- ▶ 3-ZGNRs at 5% strain:
- ▶ Still a band gap is present at the Fermi level, possesses semi conducting nature



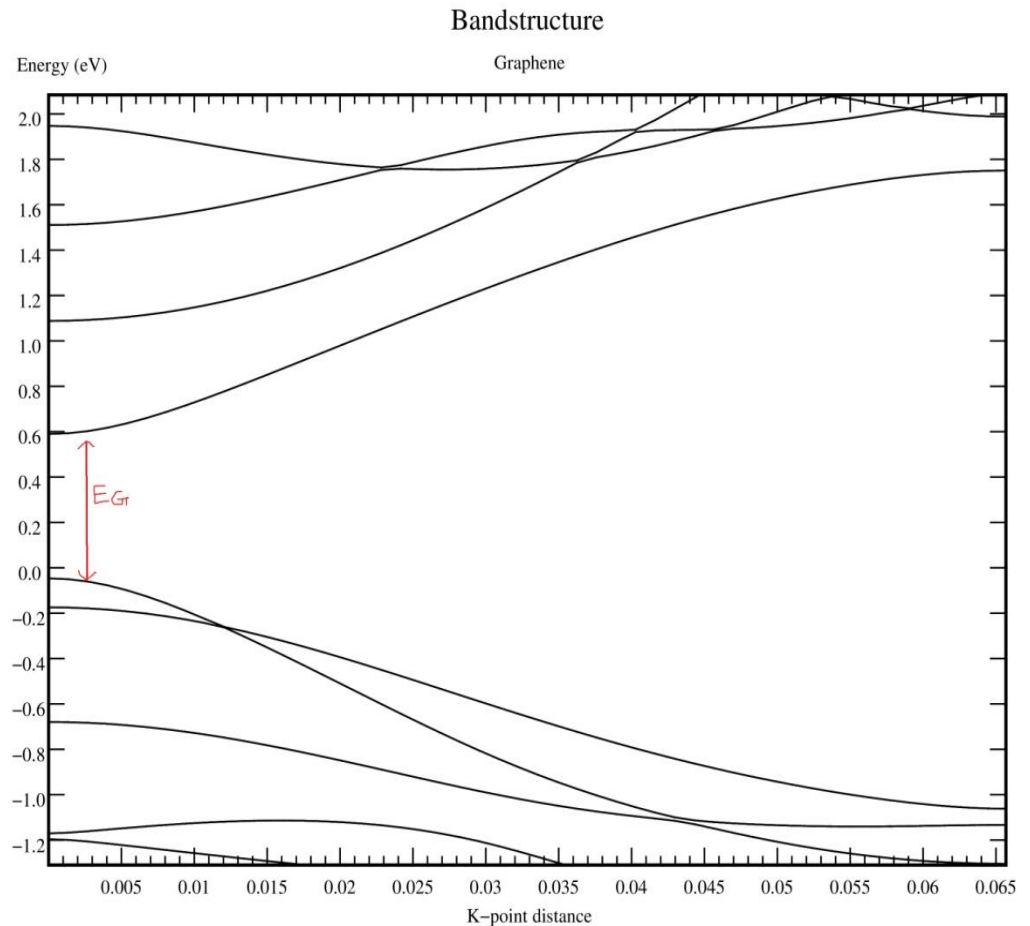
OBSERVATIONS:

- ▶ 3-ZGNRs at 6% strain and beyond:
- ▶ At Fermi level the lowermost conduction band and uppermost valance band overlap. This shows the metallicity of GNRs.



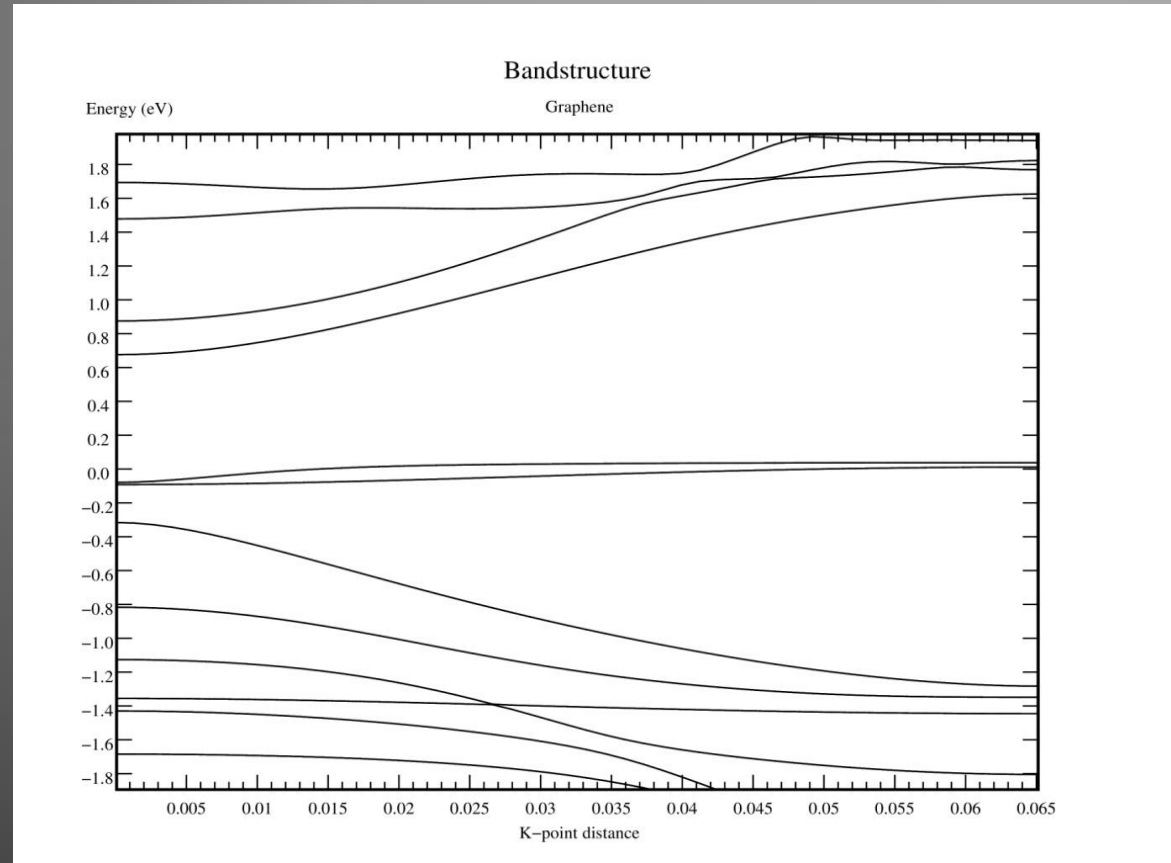
OBSERVATIONS:

- ▶ 6-ZGNRs at 3% strain:
- ▶ A band gap is present at the Fermi level, possesses semi conducting nature.



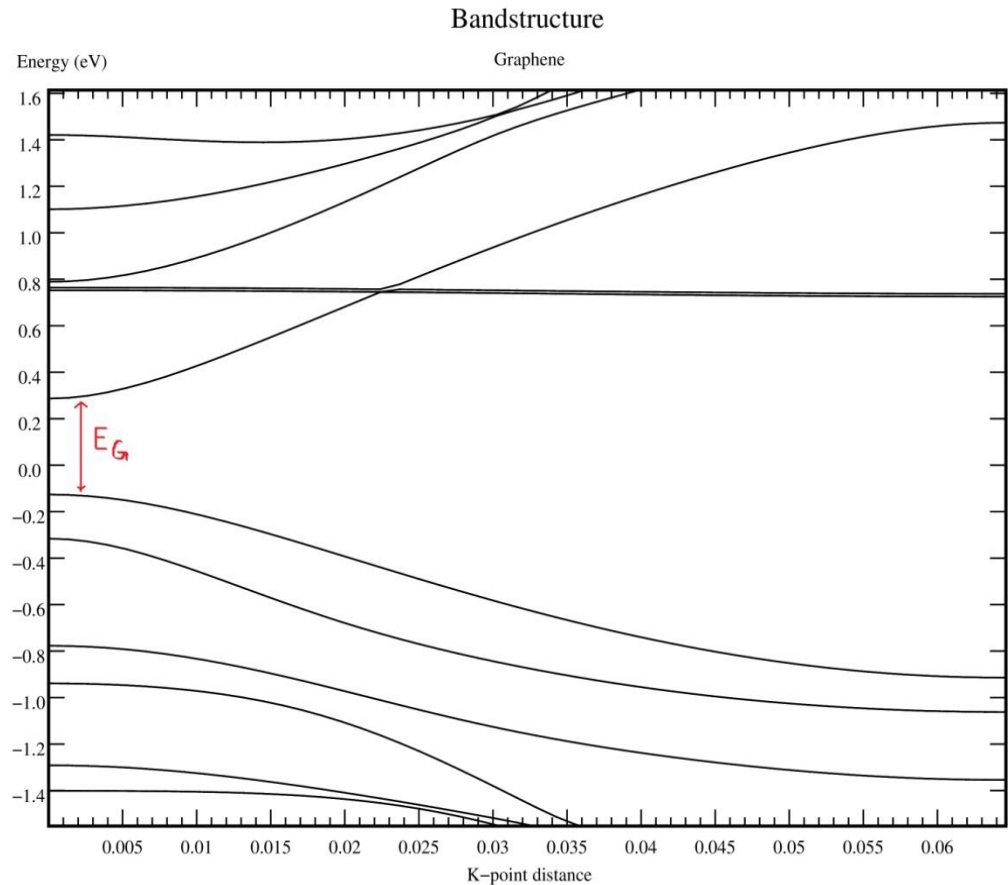
OBSERVATIONS:

- ▶ 6-ZGNRs at 4% strain and beyond:
- ▶ At Fermi level the lowermost conduction band and uppermost valance band overlap, metallic characters.



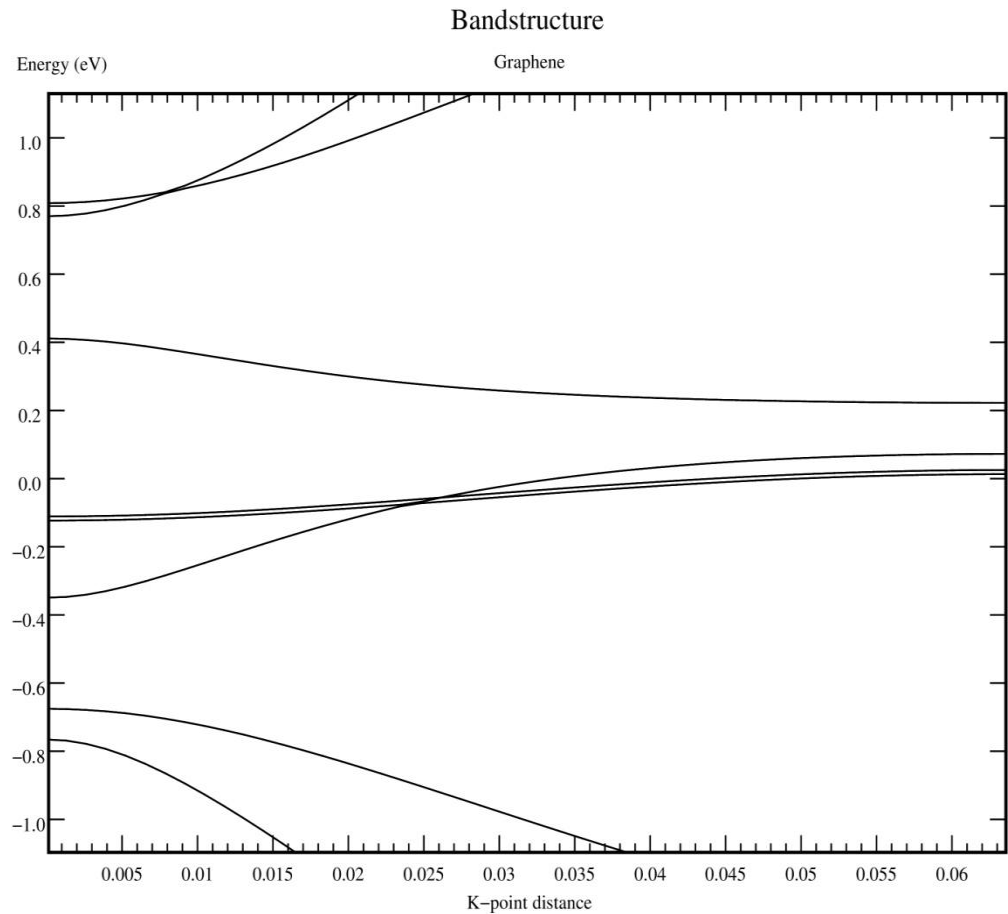
OBSERVATIONS:

- ▶ 8-ZGNRs at 5% strain :
- ▶ A band gap is present at the Fermi level, showing semiconducting nature.



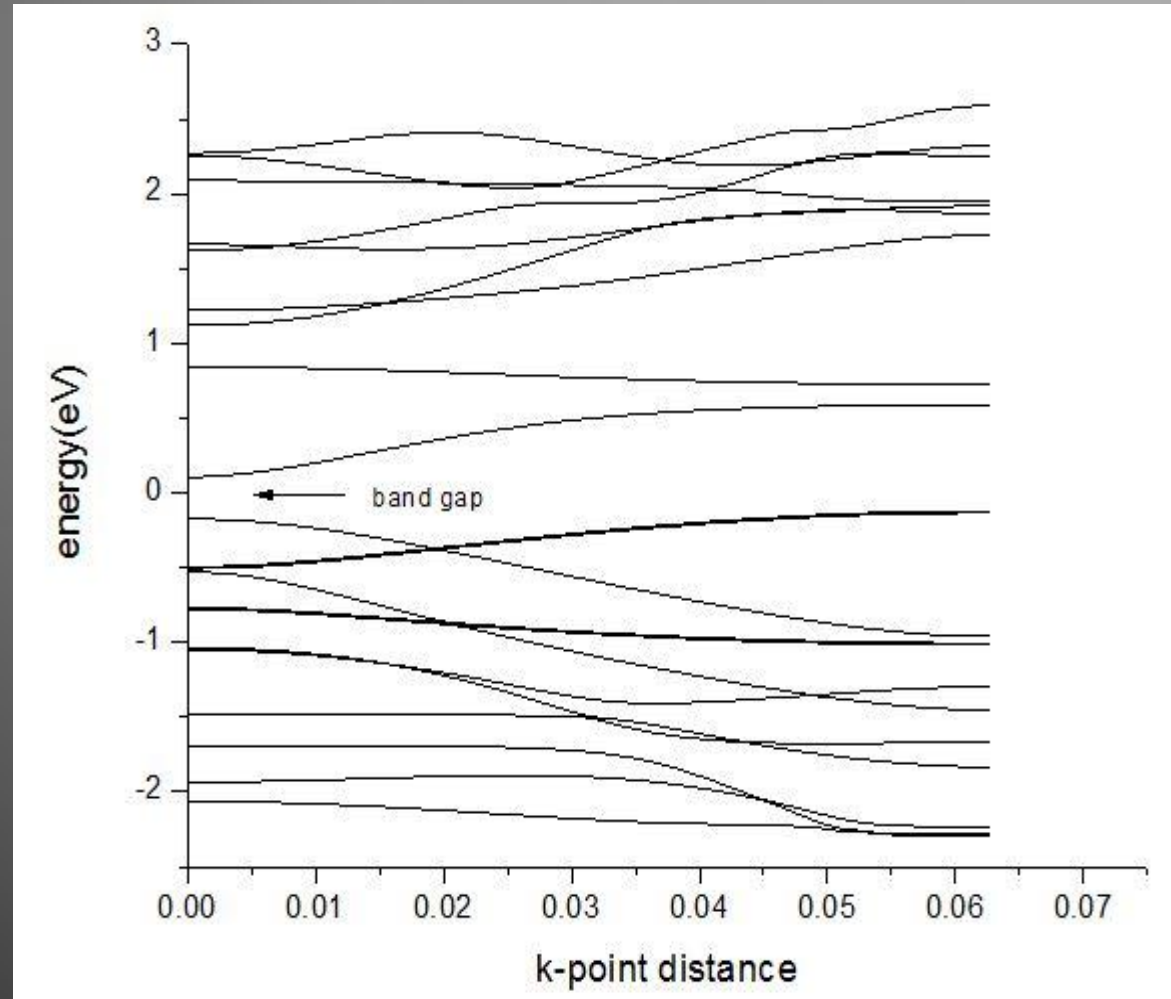
OBSERVATIONS:

- ▶ 8-ZGNRs at 6% strain:
- ▶ At Fermi level the lowermost conduction band and uppermost valance band overlap, metallic character.

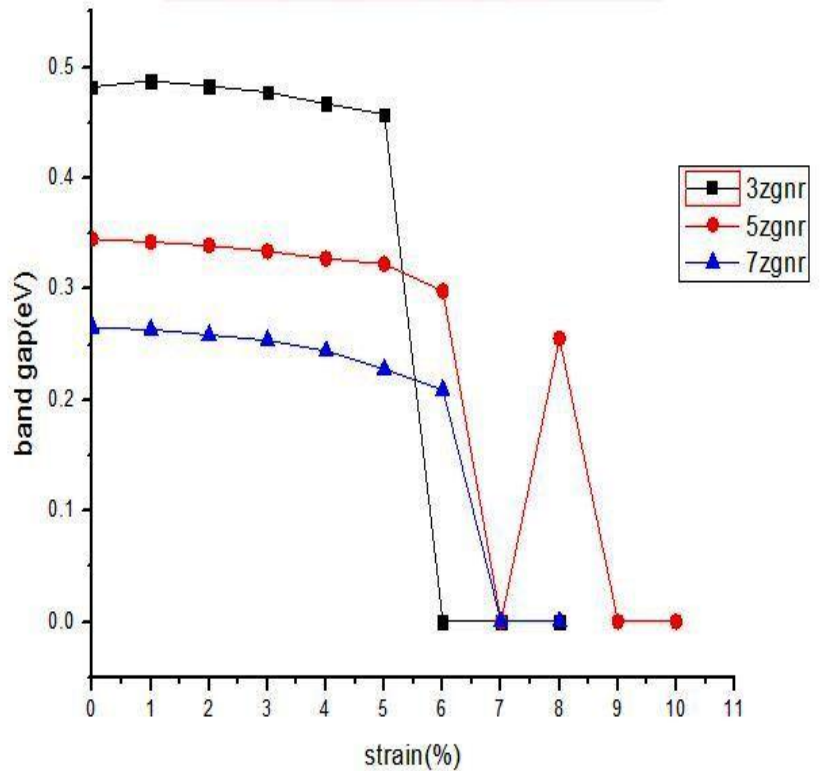


OBSERVATIONS:

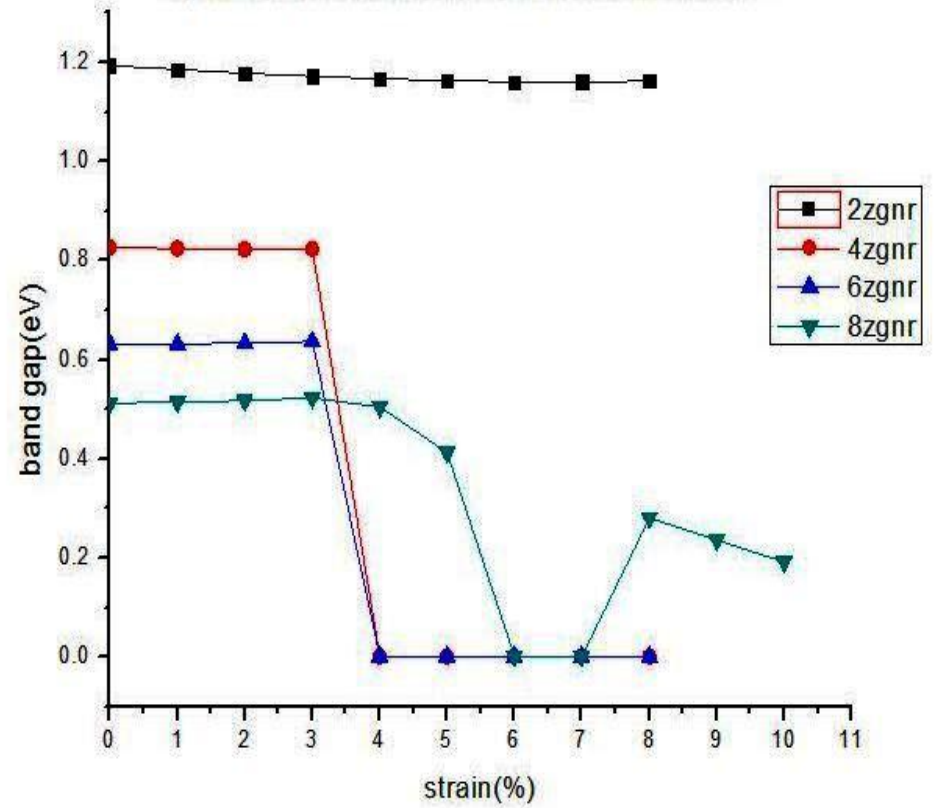
- ▶ 8-ZGNRs at 8% strain:
- ▶ There is again a band gap present at the Fermi level. It tells that the character has again shifted to semiconducting nature.



Band gap magnitude:



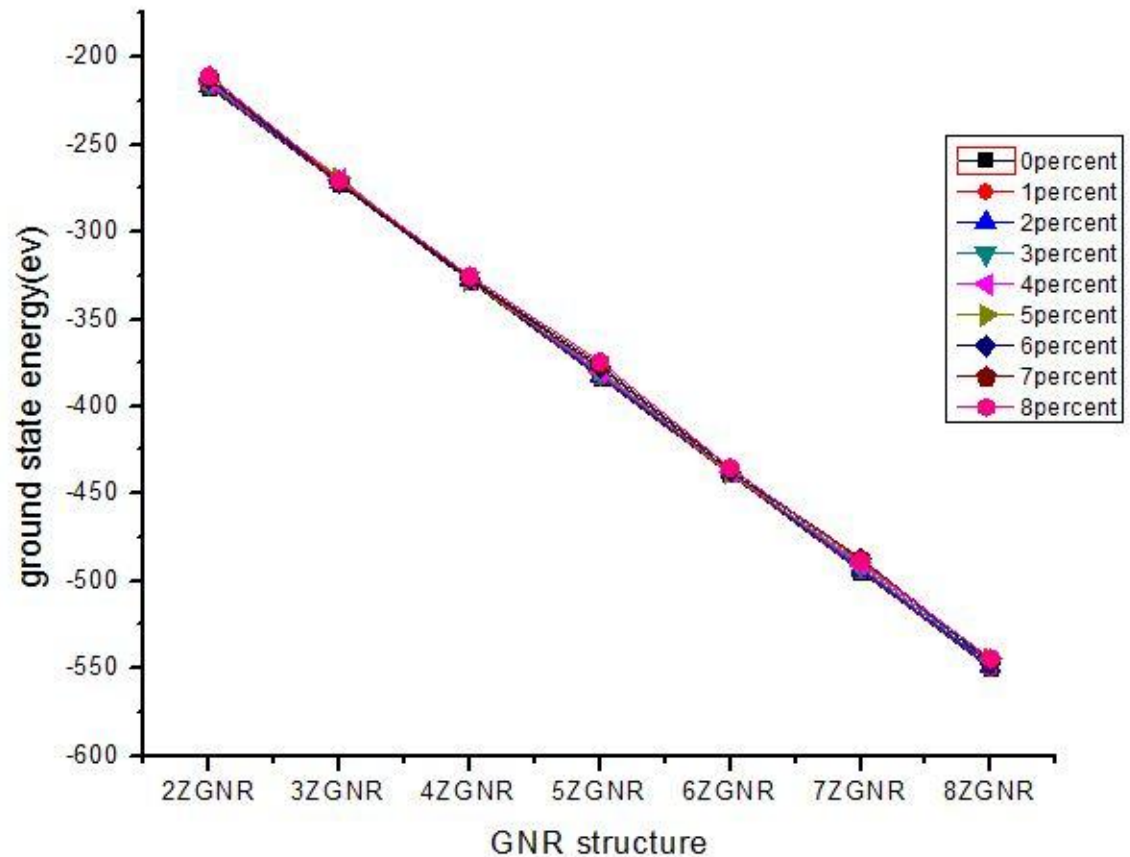
Odd-ZGNRs



Even-ZGNRs

Ground state energy for ZGNRs under strain

- The relationship is linear between all these 7 ZGNRs.
- For a particular ZGNR, the ground state energy remains almost constant under all different strains applied.

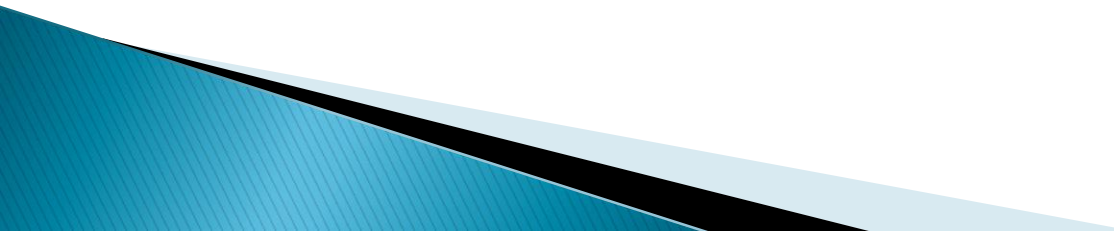


ground state energy for GNR files for different strain

TABLE I : Band gaps created by the strain in the GNRs (eV) :

Strain GNRs	0%	1%	2%	3%	4%	5%	6%	7%	8%
2- ZGNR	1.193 8	1.186 3	1.178 5	1.172 3	1.167 1	1.163 5	1.161	1.161 3	1.316 21
3- ZGNR	0.482 6	0.487 7	0.483	0.477 7	0.467 1	0.457 5	0	0	0
4- ZGNR	0.826 2	0.823 8	0.822 4	0.823 3	0	0	0	0	0
5- ZGNR	0.345 1	0.342 3	0.339 1	0.334	0.327 4	0.322 4	0.298 3	0	0.255 2
6- ZGNR	0.631 1	0.631 1	0.631 4	0.633 3	0.636 4	0	0	0	0
7- ZGNR	0.265 1	0.263 6	0.258 6	0.253 6	0.253 6	0.227 7	0.208 9	0	0
8- ZGNR	0.512 4	0.514 1	0.517 1	0.523	0.523	0.412 7	0	0	0.280 4

CONCLUSIONS:

- ▶ Electronic properties of graphene nano ribbons can be controlled by inducing strain on the GNRs.
 - ▶ Metallic and semiconducting behaviour of GNRs can be altered by inducing strain.
 - ▶ Controlling of band gaps in GNRs can be very useful for the semiconductor industry.
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THANK YOU !!